

Detector response and performance of a 500 μm thick GaAs attached to Timepix3 in relativistic particle beams

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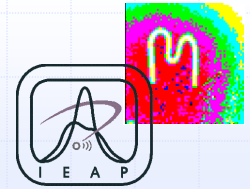
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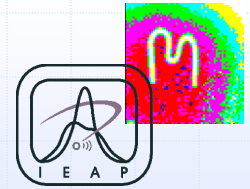
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Outline



- ❑ Motivation
- ❑ Timepix3 and GaAs:Cr
- ❑ Basic sensor characterization
- ❑ Measurement in a 40 GeV/c pion beam
- ❑ Measurement in a mixed ion beam (330 GeV/c Pb ions on target)
- ❑ Conclusion

Motivation



Main driver for development of high-Z compound semiconductor materials is X-rays imaging and γ -detection

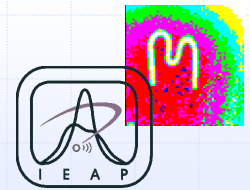
Imaging applications profit from the higher stopping power (higher efficiency of photoeffect)

Why to use it for particle tracking?

- High charge carrier mobility \rightarrow increased speed of operation
- Higher stopping power
- Expected higher radiation tolerance
- Particle identification using a combination of X-ray detection and tracking (Transition radiation detector)*

Disadvantages: Thermal stability, higher leakage current, sensor inhomogeneity, charge carrier lifetime ...

* F. Dachs *et al*, "Transition radiation measurements with a Si and a GaAs pixel sensor on a Timepix3 chip", Nuclear Instruments and Methods in Physics Research Section A: Accelerators, Spectrometers, Detectors and Associated Equipment, 2019, <https://doi.org/10.1016/j.nima.2019.03.092>.



Timepix3 detector and GaAs:Cr



Timepix3

- ❑ 256 x 256 pixels with 55 μm pitch (1.98 cm^2 sensitive area)
- ❑ Minimal detection threshold in each pixel is 500 e^-
- ❑ Each pixel measures energy deposit (ToT) and time of interaction (ToA, precision 1.5625 ns)
- ❑ Data driven-readout (data are send on an event-by-event base)

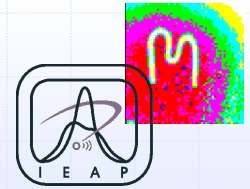
Sensor layer:

- ❑ Chromium compensated GaAs from Tomsk State Universty
- ❑ Thickness 500 μm
- ❑ Ohmic contacting scheme

Readout:

- ❑ AdvaDAQ (pion measurement)
- ❑ Katherine readout (characterization, mixed ion beam)

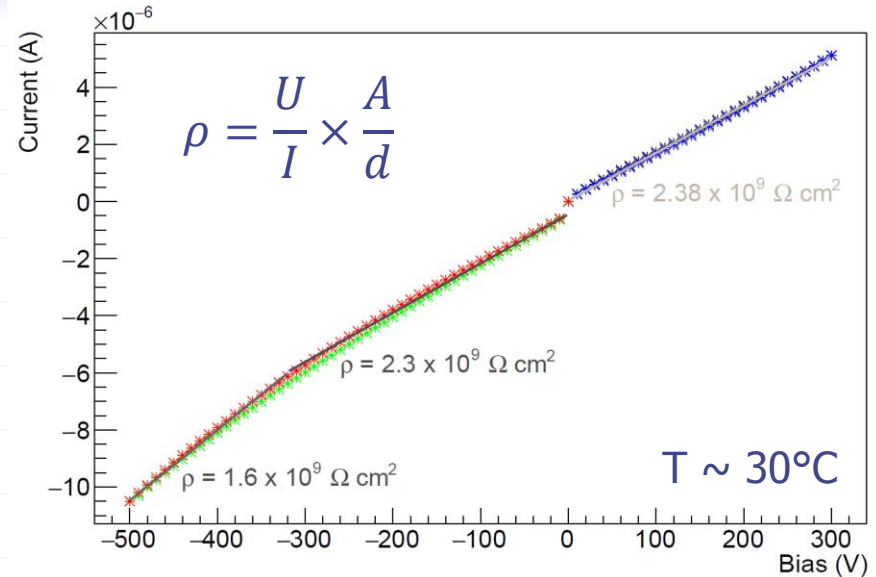
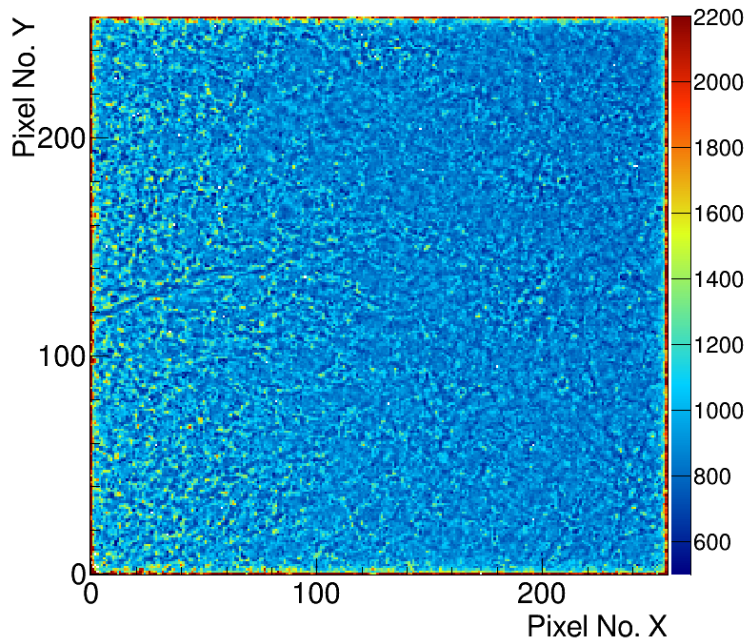
Basic sensor characterization: I-V curve and count rate homogeneity



I-V curve measurement:

- Measurement of the leakage current as function of the applied bias
- Line fit used to determine the sensor resistivity

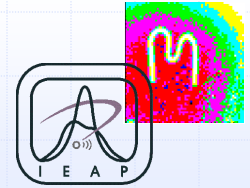
Americium (59.6 keV)



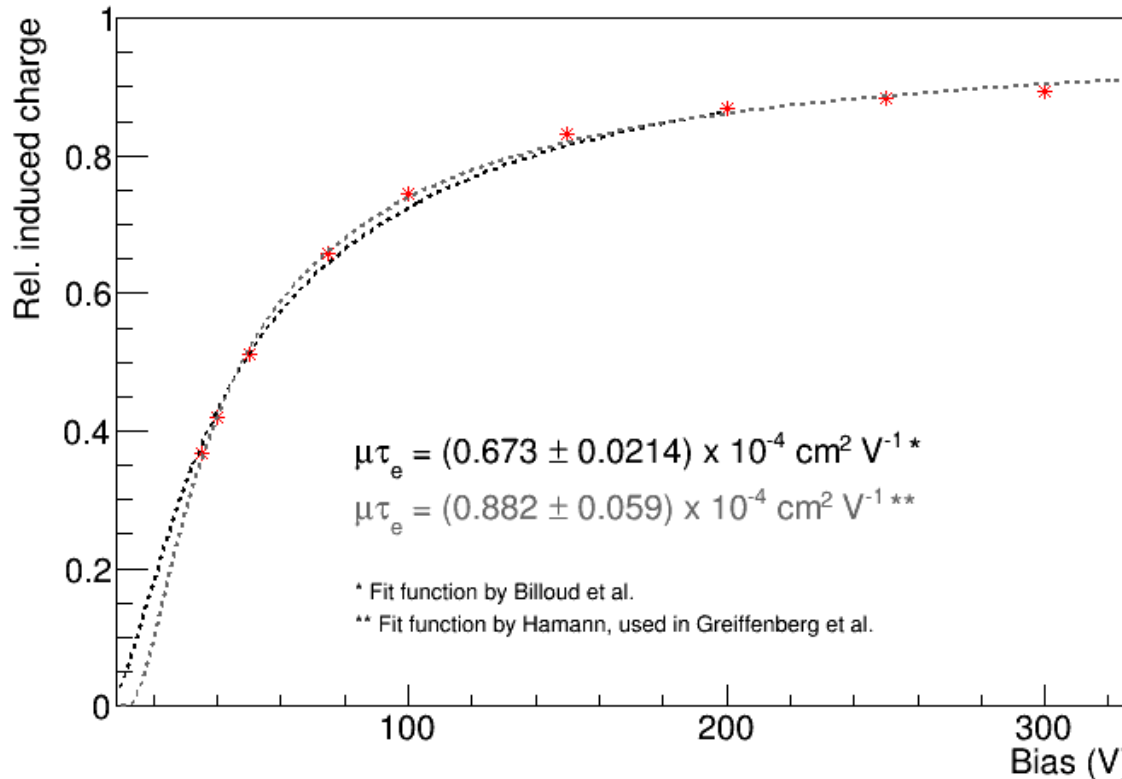
Count rate homogeneity:

- Sensor irradiated by 59.6 keV γ -rays from an ^{241}Am source
- Good homogeneity

Basic sensor characterization: Determination of the $\mu\tau_e$ -product



- ❑ Irradiation of the GaAs:Cr sensor with K-line photons of zirconium (15.77 keV)
- ❑ Determine the peak position of single pixel clusters E_{peak} as a function of the applied bias U_{bias}

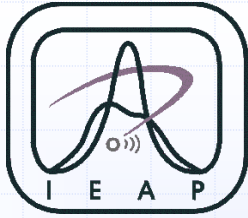


Induced charge is defined as $E_{\text{peak}}/E_{\text{K-line}}$

Sensor temperature:
 $T_{\text{sensor}} \sim 50^\circ\text{C}$

* T. Billoud *et al*, "Homogeneity study of a GaAs:Cr pixelated sensor by means of X-rays", JINST 13 P04002, 2018.

** Greiffenberg *et al*, "Characterization of GaAs:Cr sensors using the charge-integrating JUNGFRÄU readout chip", JINST 14 P05020, 2019.

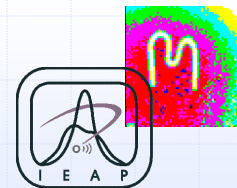


Measurements in a 40 GeV/c pion beam

- Super-proton-synchrotron at CERN
- Irradiation at 60° wrt the sensor normal
- Sensor used in electron collection (negative polarity)
- Bias varied in the range from -25 V to -500 V
- Study of the sensor material properties (drift time, charge collection efficiency)

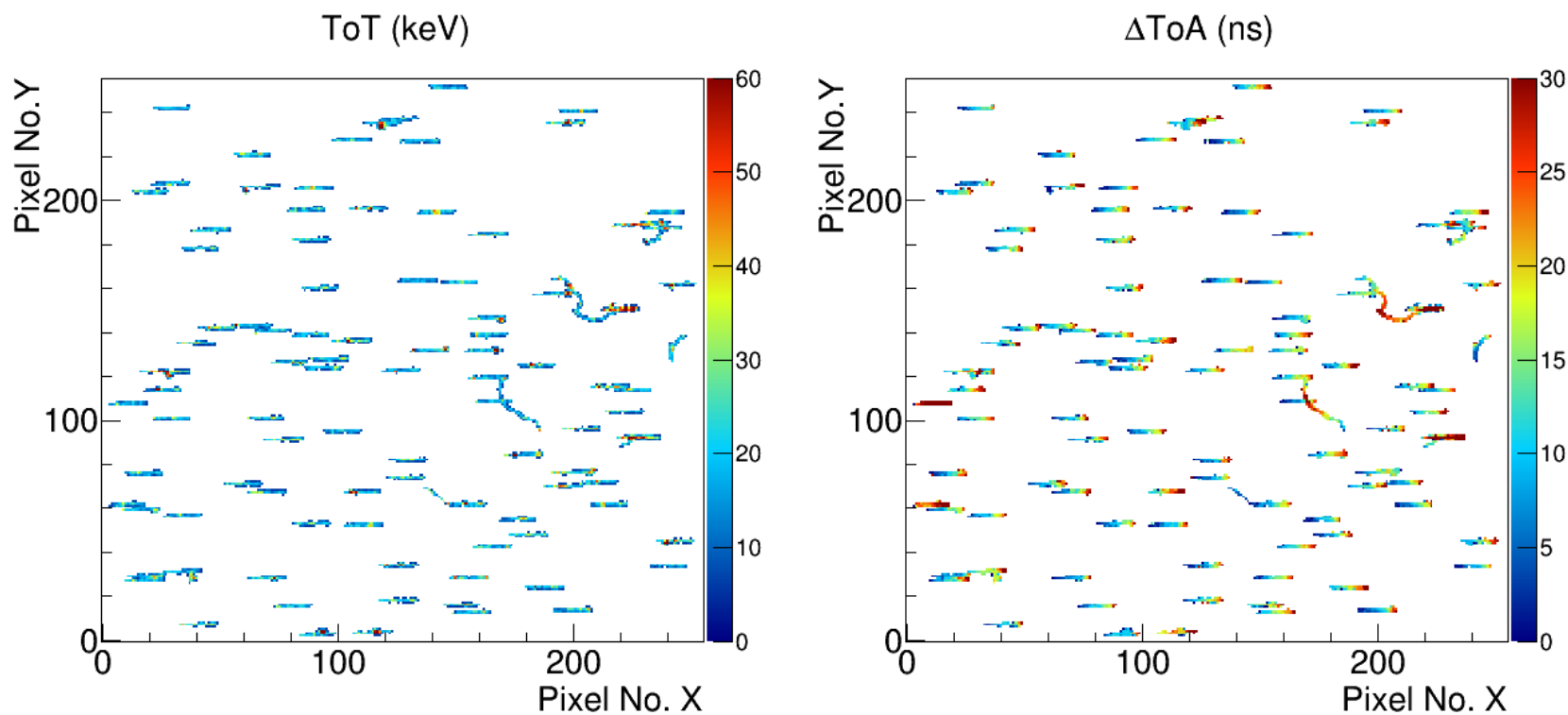


40 GeV/c pion beam: 60 deg – Typical tracks

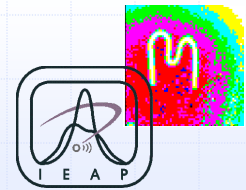


Collection of 100 tracks measured at 60 deg irradiation at bias -25 V

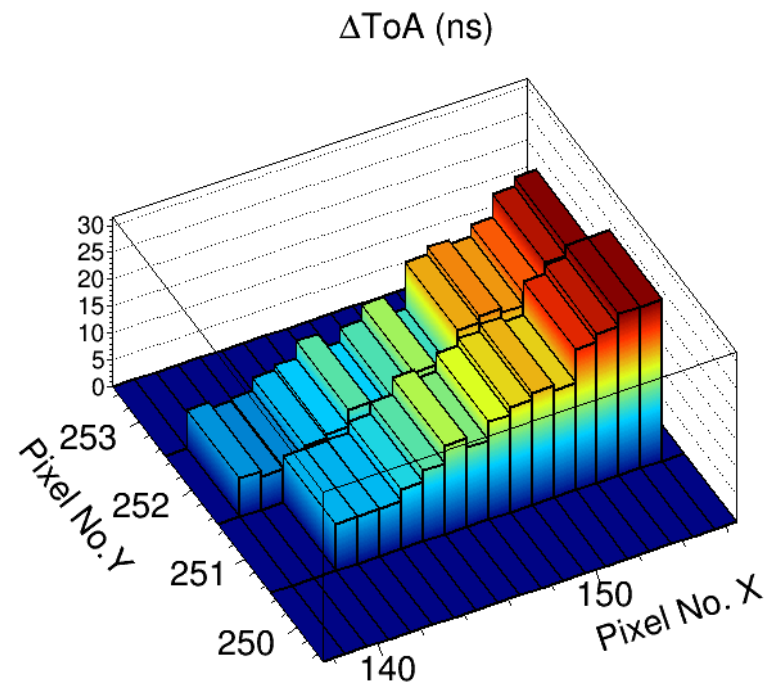
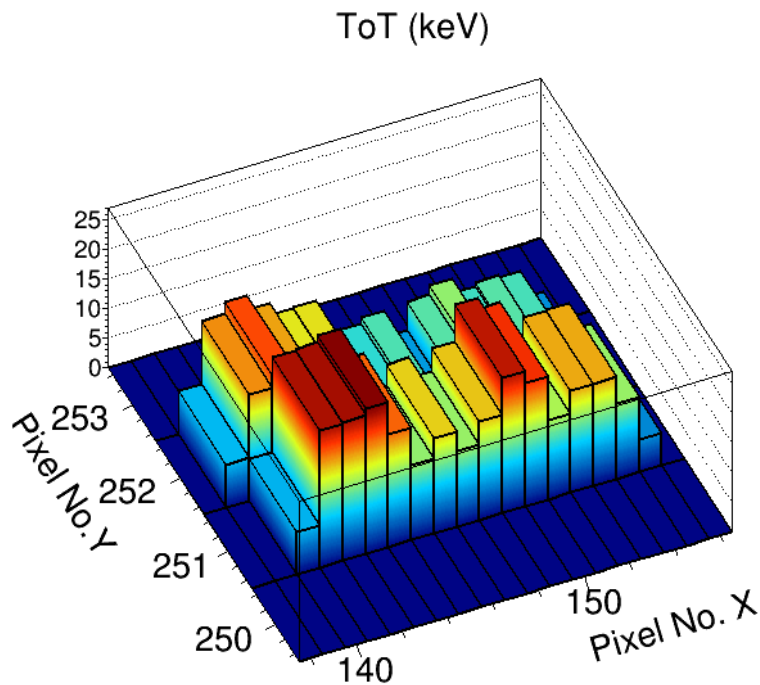
- Energy deposition (left)
- Relative time difference within a track (right)



40 GeV/c pion beam: 60 deg – Single event analysis

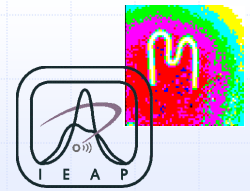


- ❑ Increase of the time with increasing distance to the pixel electrodes
- ❑ Overall decrease of energy with increasing distance to the pixel electrodes
- Study drift time (ΔToA) and charge collection efficiency (ToT) as a function of z

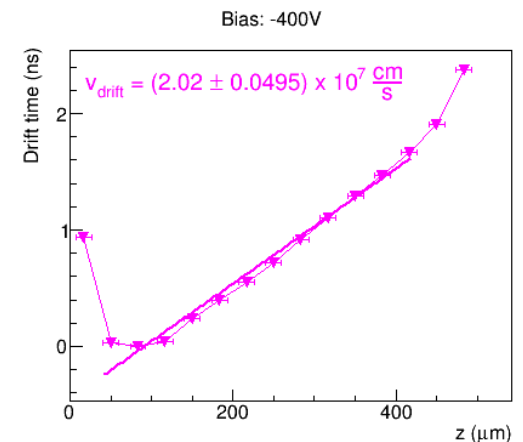
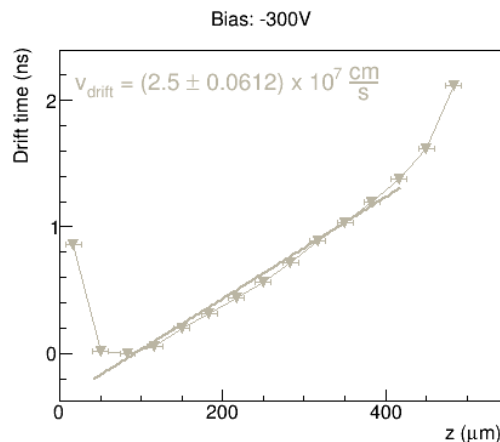
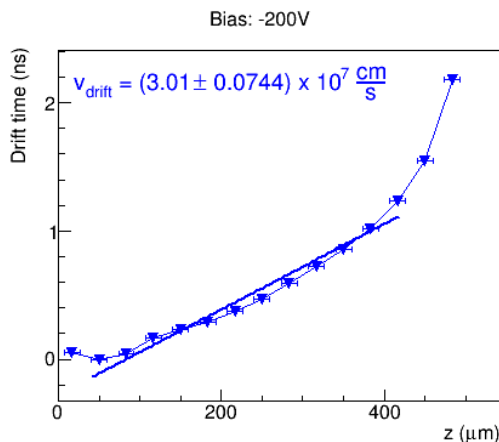
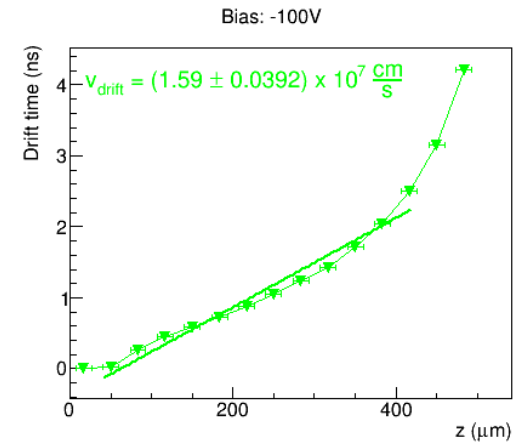
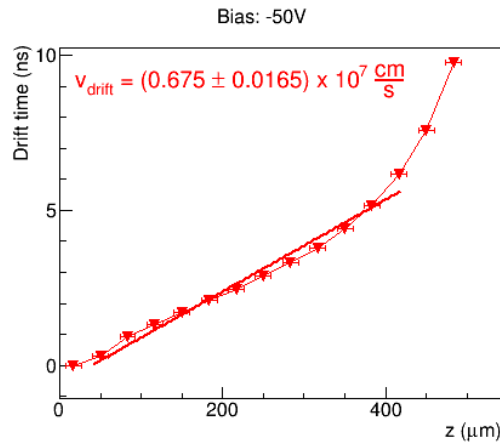
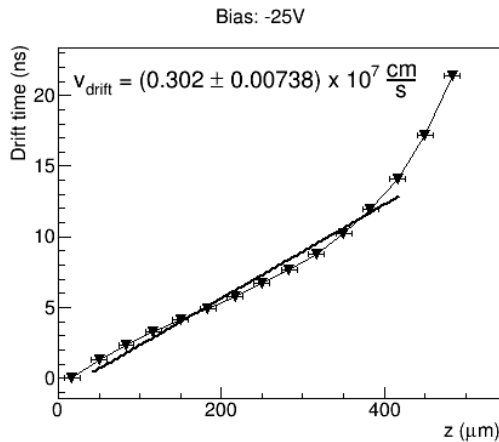


Bias: -25 V

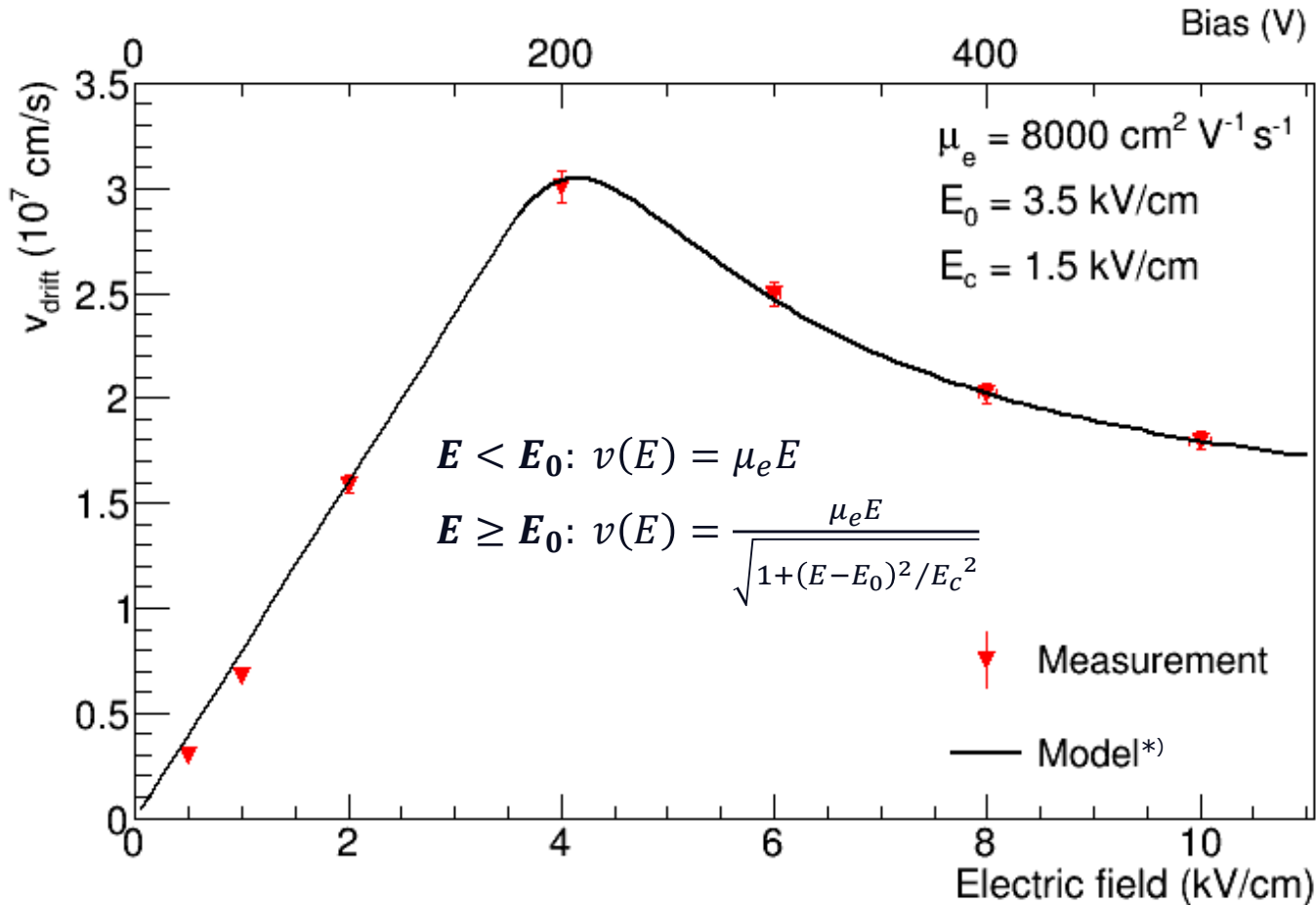
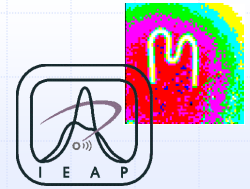
40 GeV/c pion beam: 60 degrees - Drift time analysis



Slope of the presented curves is $\frac{1}{v_{drift}}$ (determined by fitting)



40 GeV/c pion beam: 60 degrees – Drift velocity and electron mobility



Electric field:

$$E = \frac{U_{Bias}}{d}$$

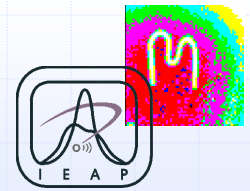
U_{bias} : Bias voltage

d : Thickness

v_{drift} saturates and decreases above the electric field E_0

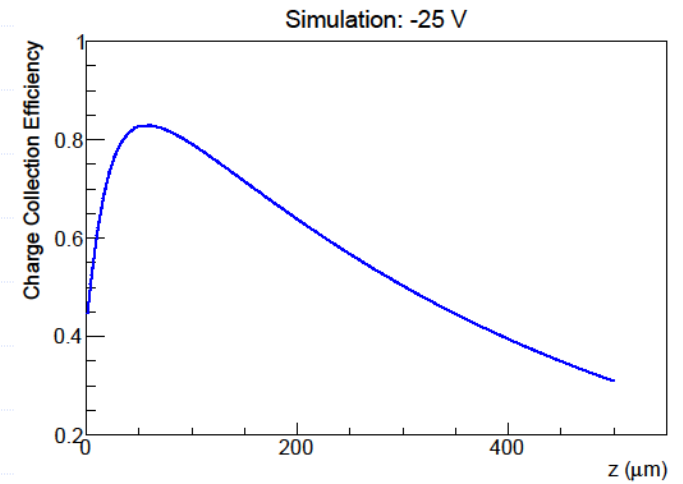
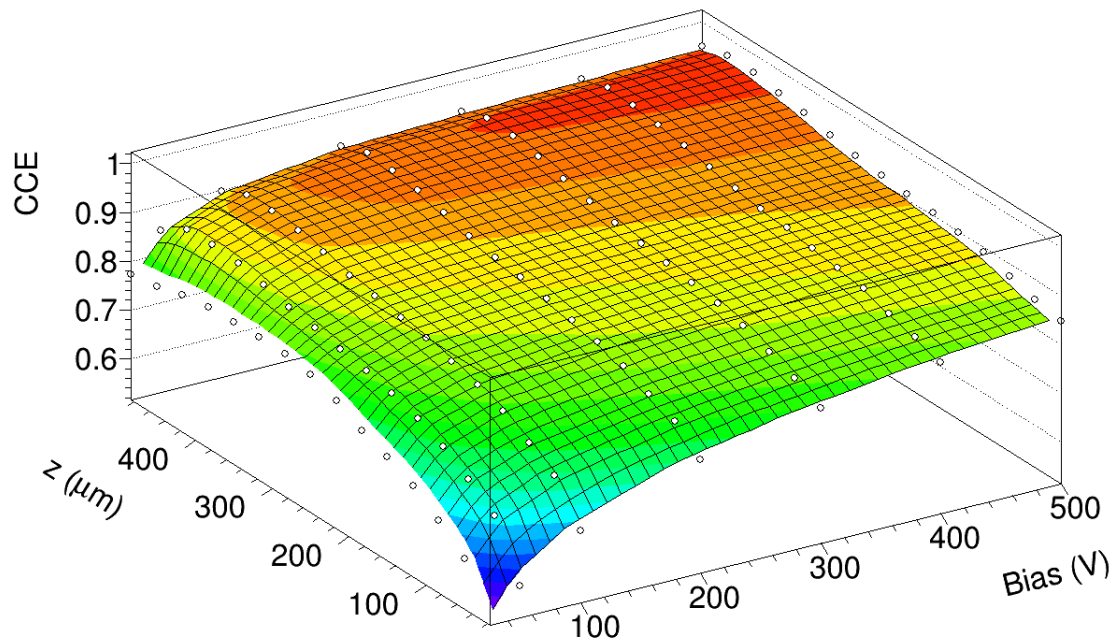
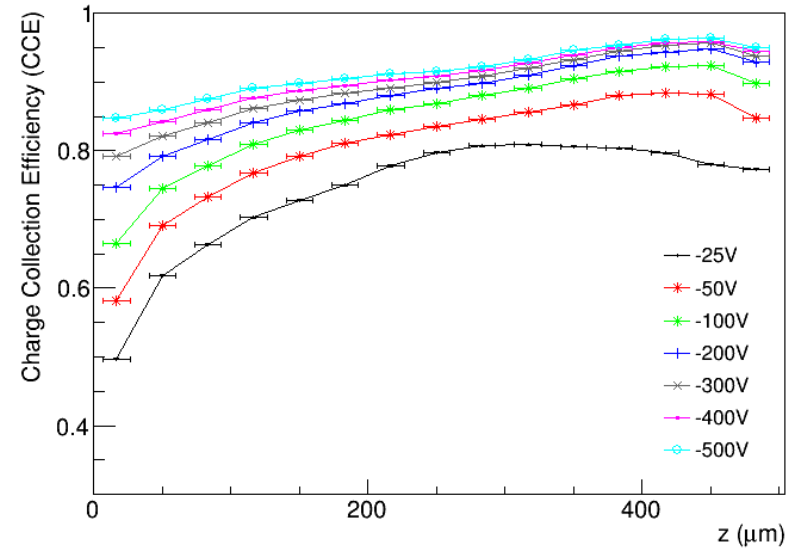
*) A. Dargys and J. Kundrotas, „Handbook on Physical Properties of Ge, Si, GaAs and InP“, Science and Encyclopedia Publishers, Vilnius, 1994

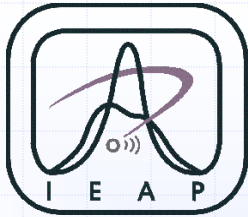
40 GeV/c pion beam – 60 degrees - Charge Collection Efficiency



CCE extracted from the energy deposition profile of the track

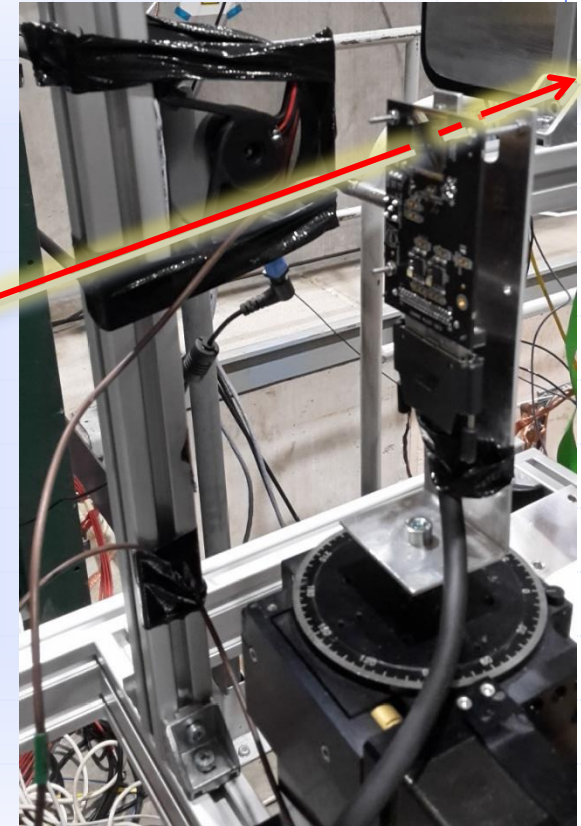
- Higher charge collection efficiency as expected from simulation
- Behavior of the charge collection efficiency cannot be explained



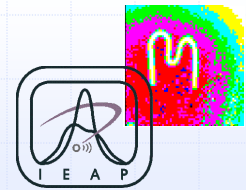


Measurements in mixed ion beam after 330 GeV/c Pb impact on target

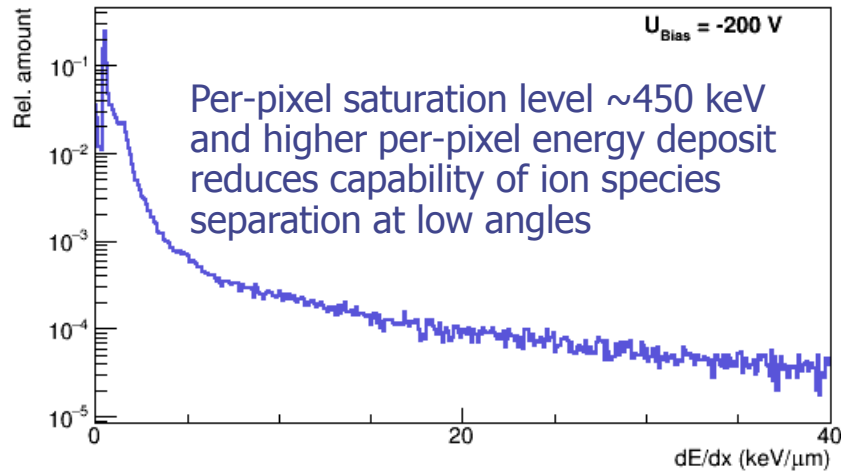
- Super-Proton-Synchrotron at CERN
- Sensor used in electron collection (neg. polarity)
- Results at bias -200 V are shown
- Data at angles 0° , 25° , 50° and 75° (wrt the sensor normal)
- Study the detection and separation capability of multiply charged particles



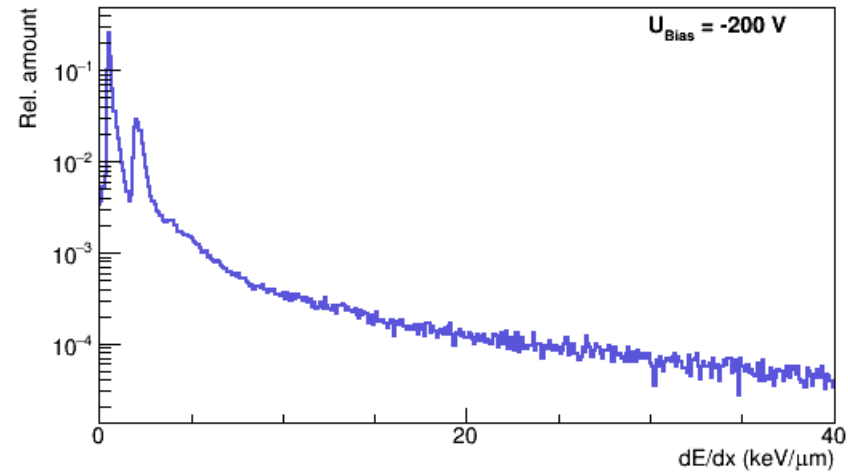
330 GeV/c Pb impact on target: Stopping power spectra at different angles



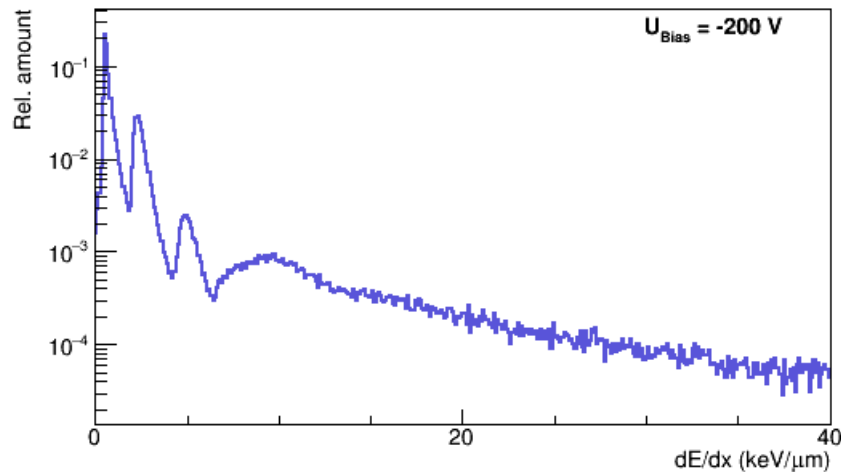
Mixed ion beam: 0 deg



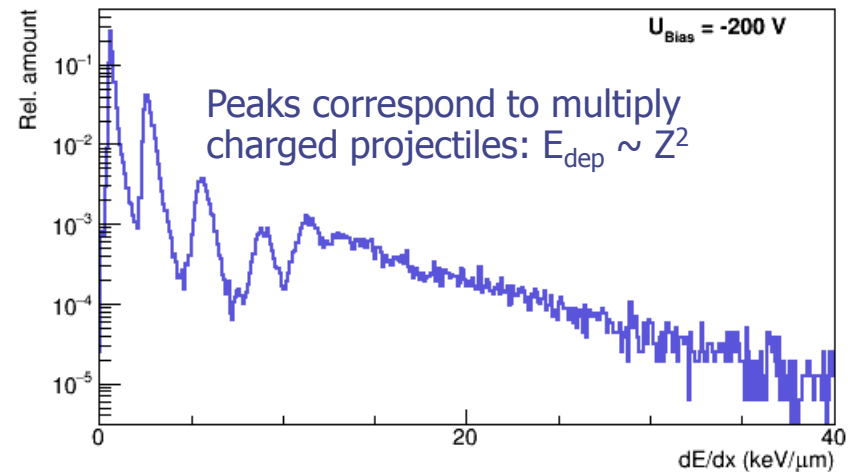
Mixed ion beam: 25 deg



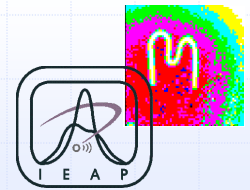
Mixed ion beam: 50 deg



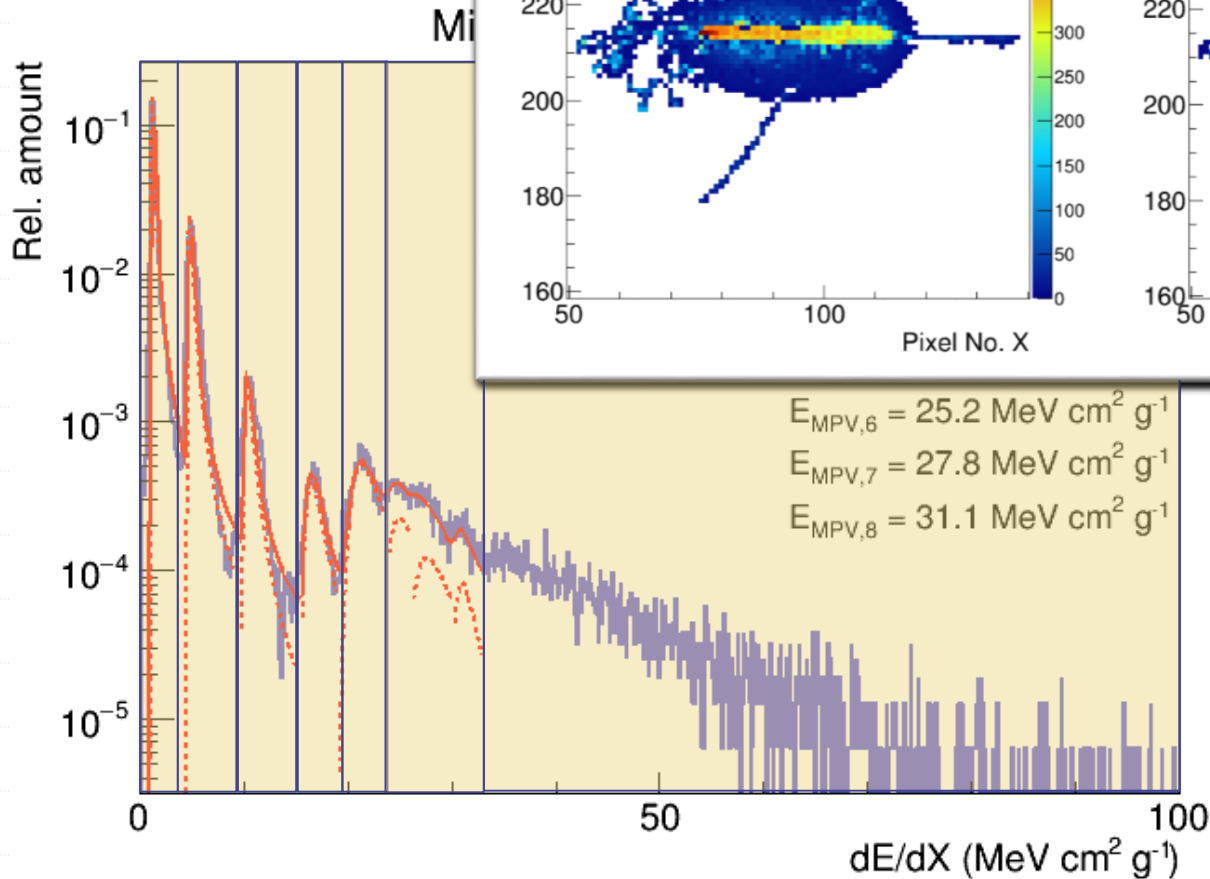
Mixed ion beam: 75 deg



330 GeV/c Pb impact on target: Impact at 75 degree – Landau fitting and track shapes



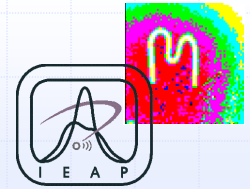
Energy deposition spectra described by Landau functions.



A halo becomes pronounced from the 3rd peak.

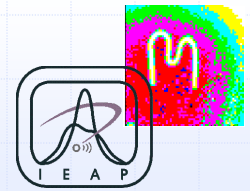
Halo starts to grow from the side, where the track is close to the pixels.

Conclusion

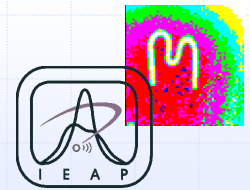


- ❑ The detector response of a 500 μm thick GaAs:Cr was studied in relativistic particle beams
- ❑ Measurement in a 40 GeV/c was used to study drift times of electrons and the charge collection efficiency as functions of interaction depth at different bias voltages
 - ❑ The drift time measurement was consistent with $\mu_e = 8000 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$
 - ❑ Drift velocity saturation was found at electric fields above $E_0 = 3.5 \text{ kV/cm}$
- ❑ The particle species separation capability was studied in a mixed relativistic ion beam at different angles
 - ❑ The higher the impact angle the more species could be identified by stopping power
 - ❑ For low angles saturation of pixel electronics ($\sim 500 \text{ keV}$) reduces particle species separation capability
 - ❑ For heavier ions a halo becomes visible. It is delayed by $\sim \mu\text{s}$.

Thank you for your attention!



Back-up



Electric field GaAs:Cr sensors

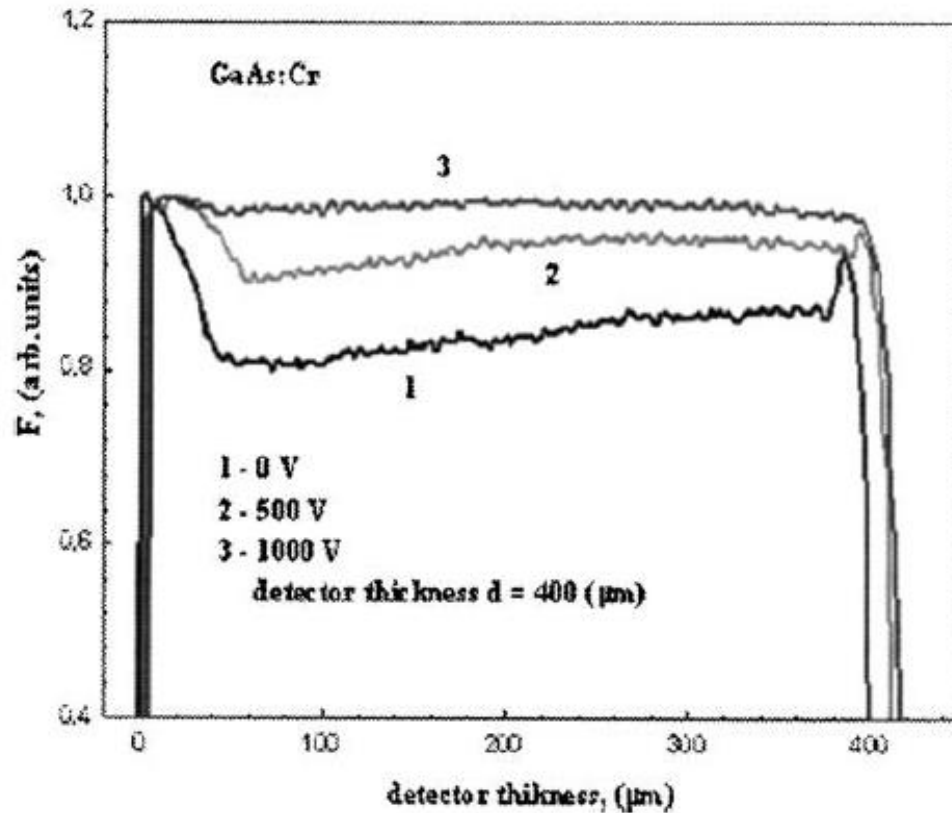
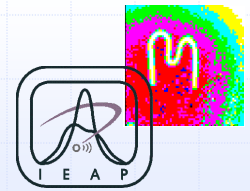


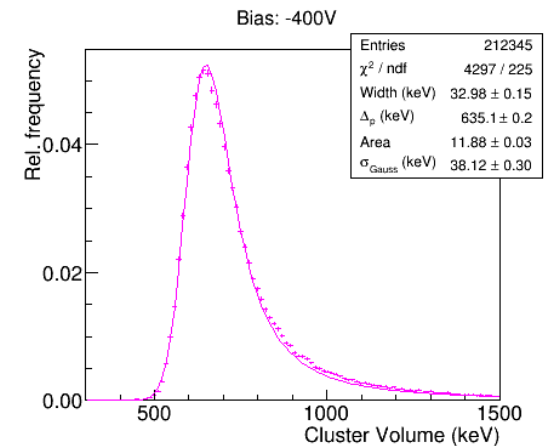
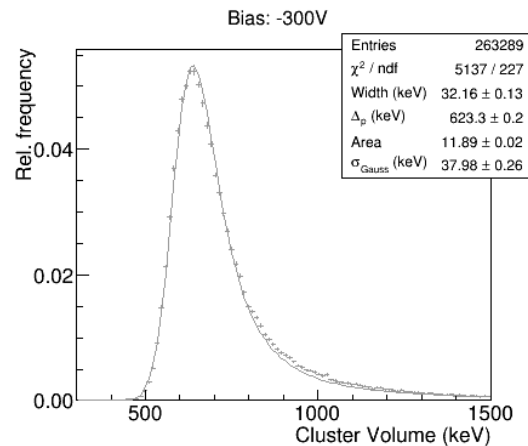
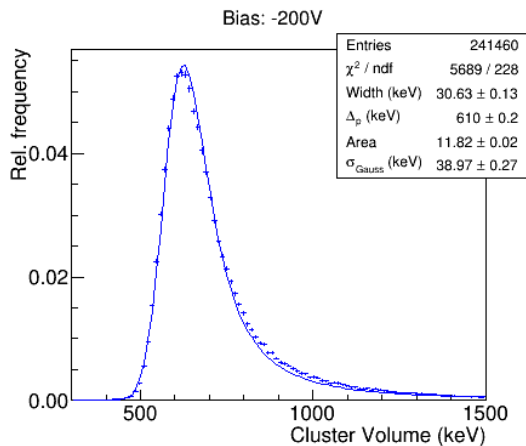
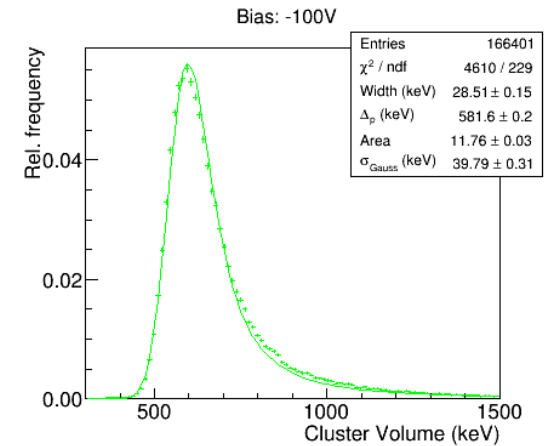
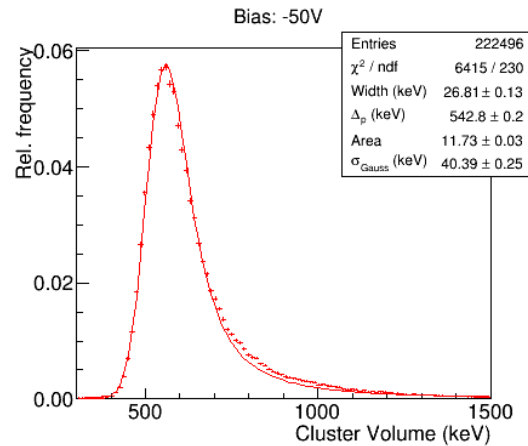
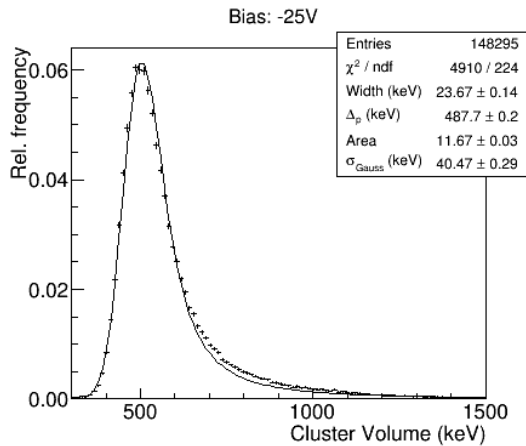
Fig. 8. The spatial distribution of function F through the detector thickness for various bias voltages (GaAs:Cr).

A.V. Tyazhev et al., "GaAs radiation imaging detectors with an active layer thickness up to 1mm", Nuclear Instruments and Methods in Physics Research A 509 (2003) 34–39.

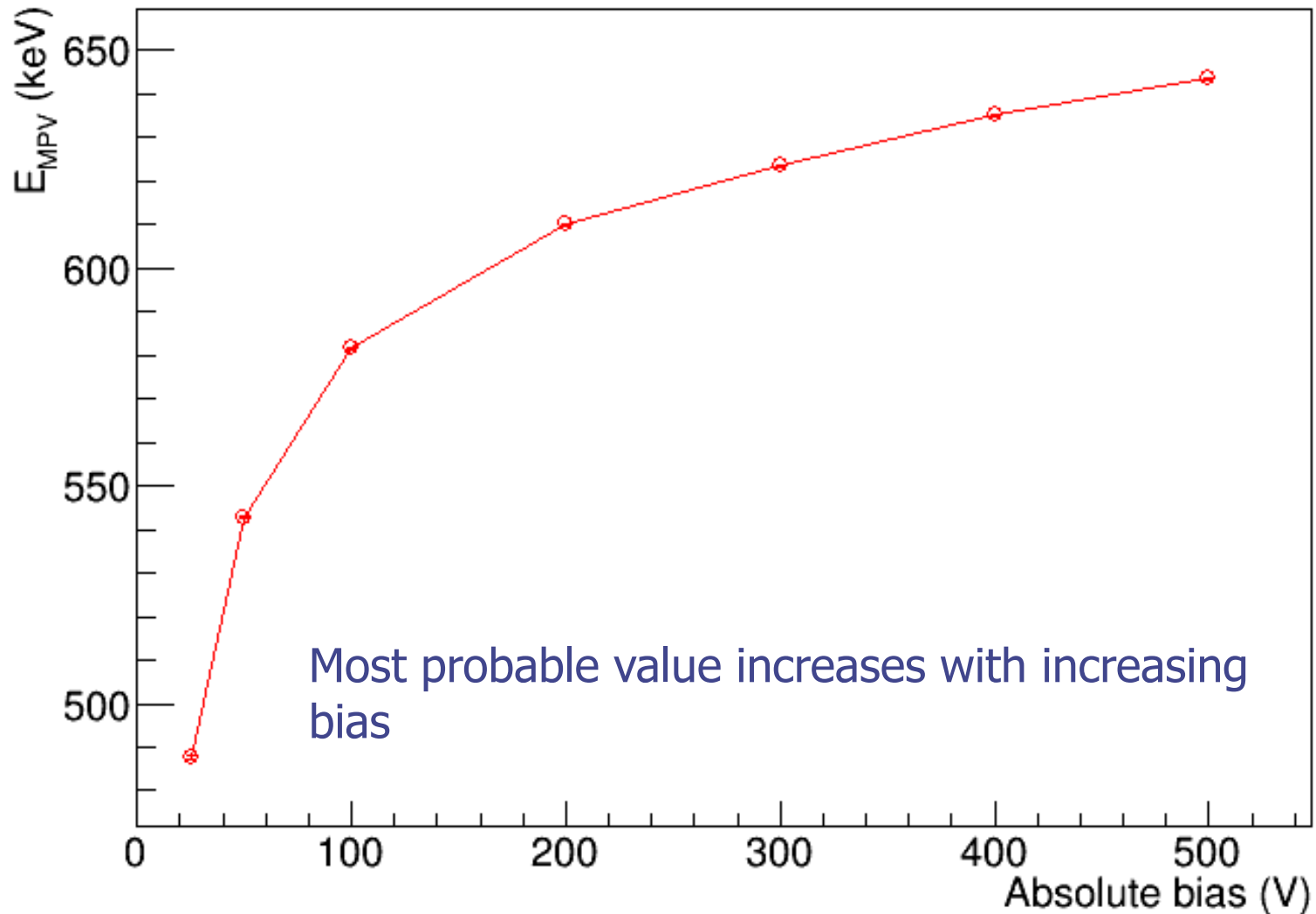
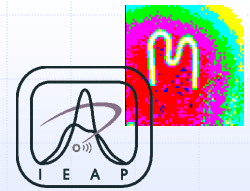
40 GeV/c pion beam: 60 deg – Energy spectra



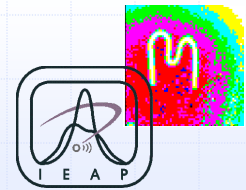
Energy deposition spectra are fitted by a Landau-distribution (physics of interaction in the medium) convoluted with a Gaussian (energy resolution)



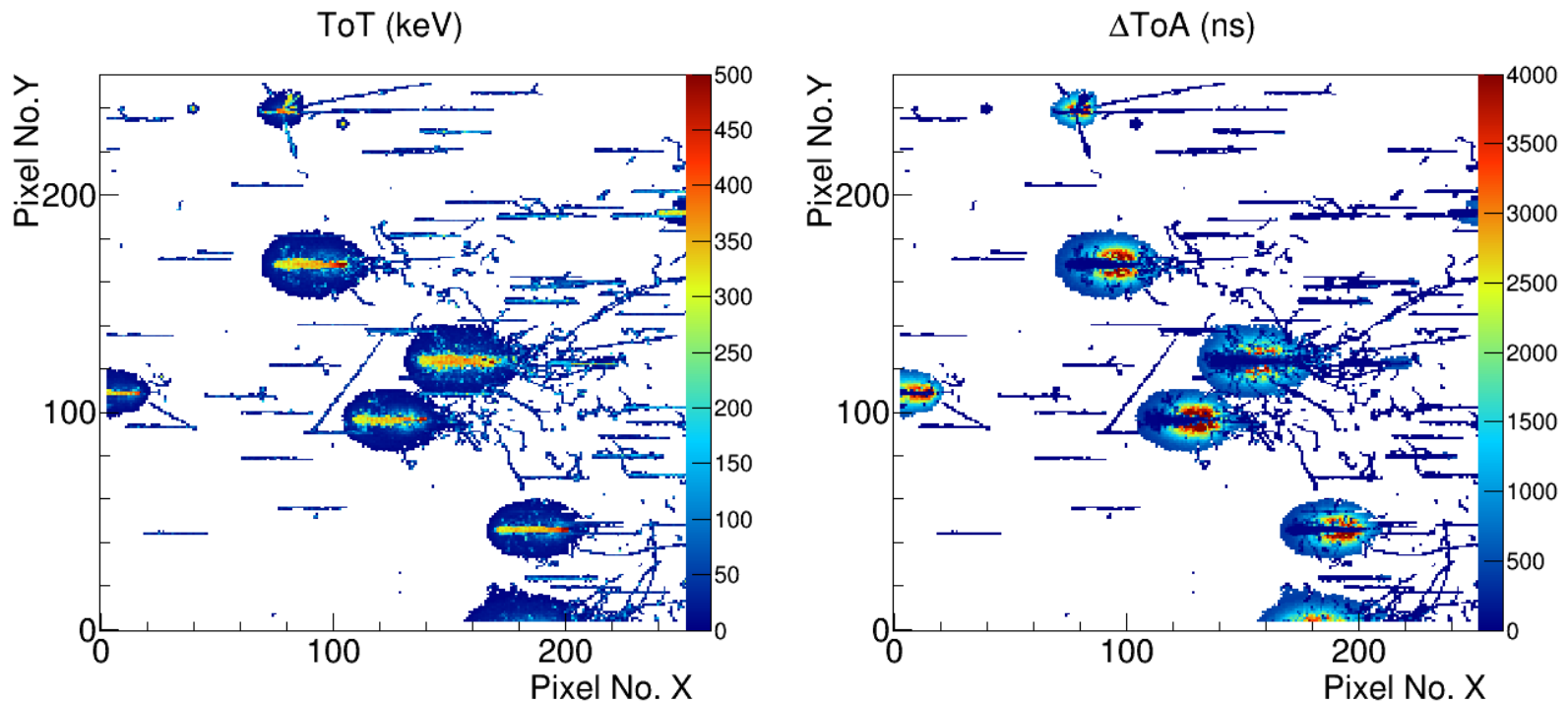
40 GeV/c pion beam: 60 degrees – Most probable value vs. bias voltage



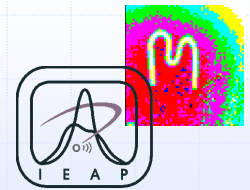
330 GeV/c Pb impact on target: Impact at 75 degree – Typical tracks



- Example tracks:

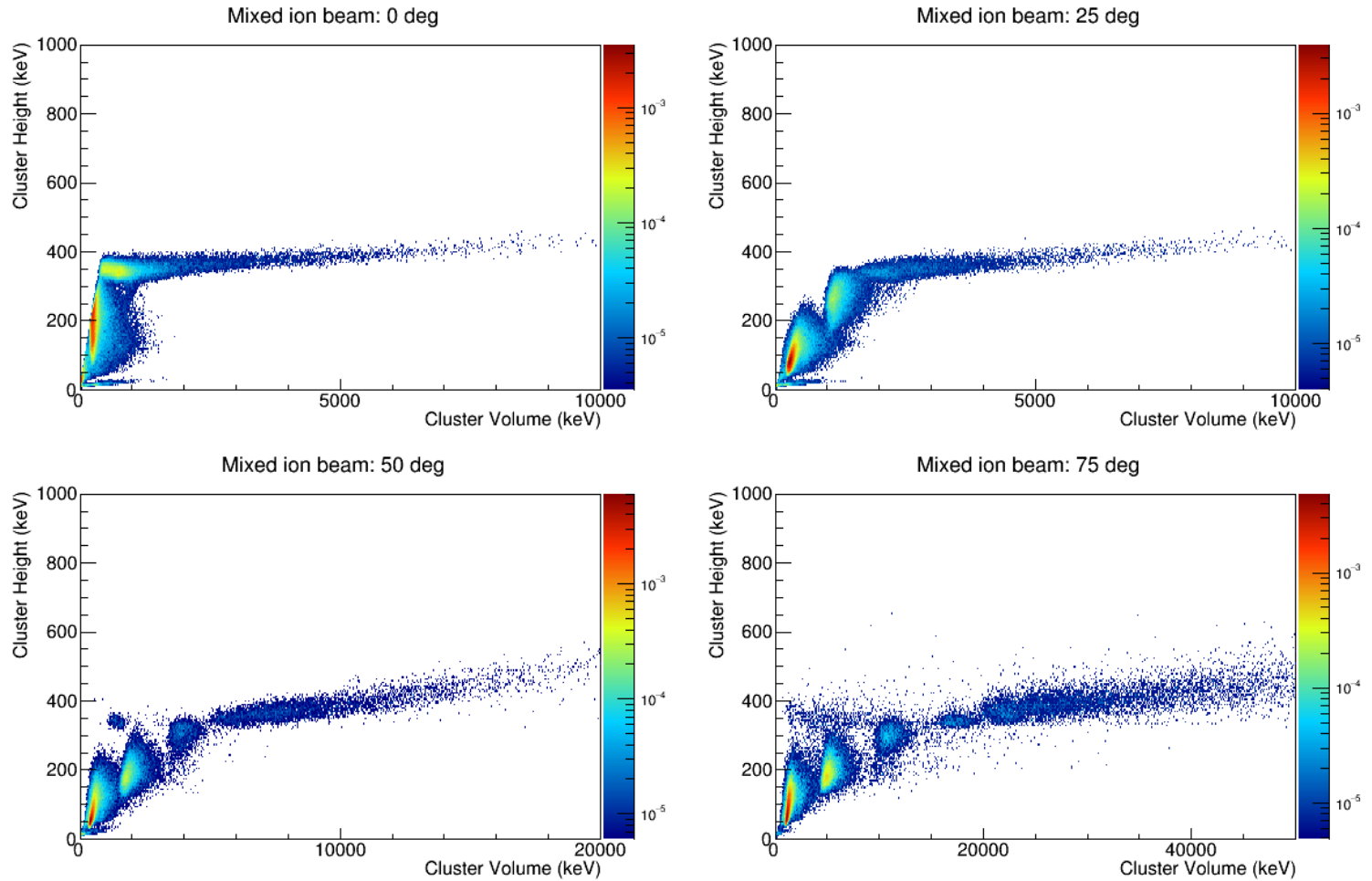


Events measured at an impact angle of 75 degrees

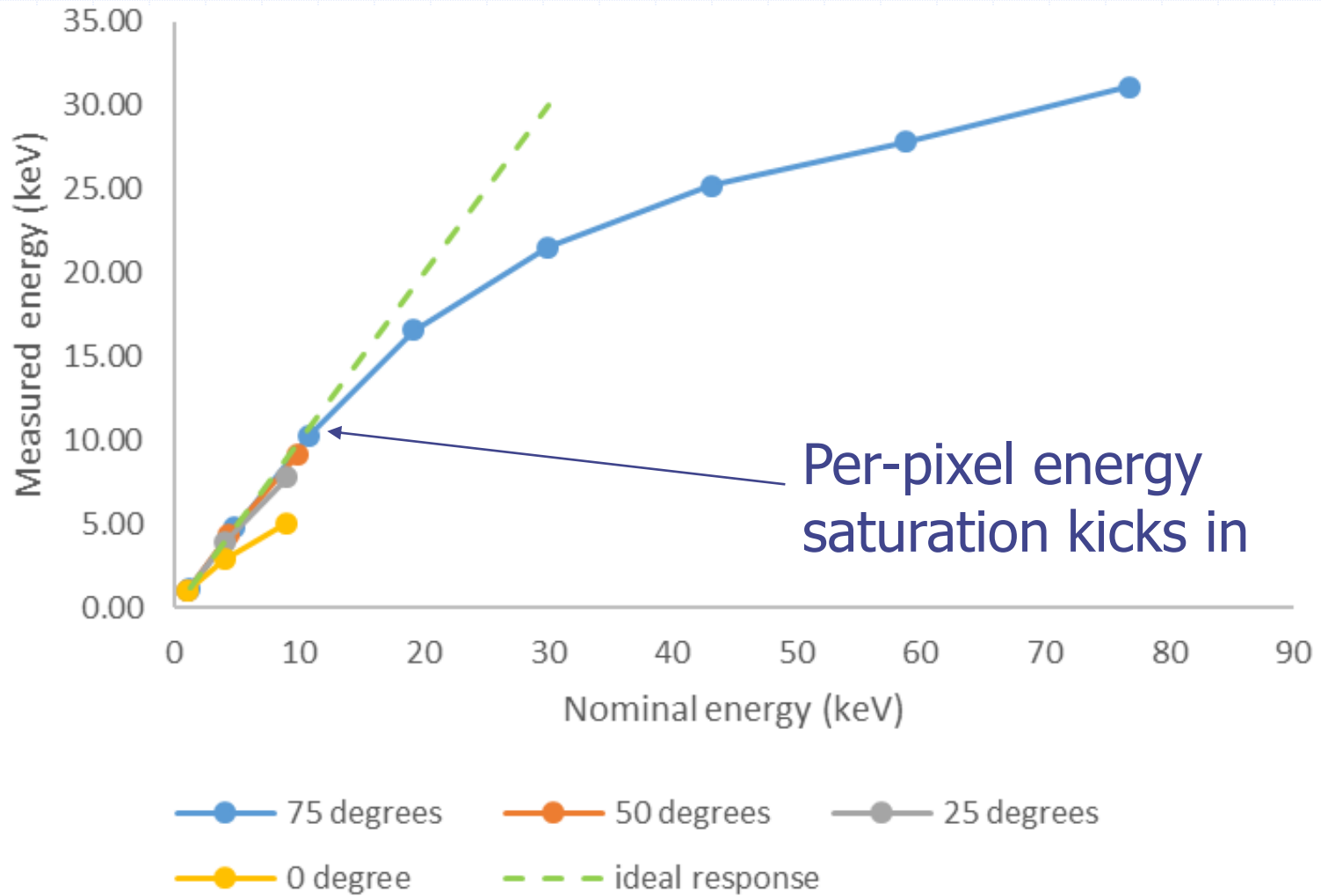
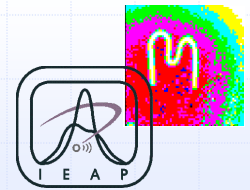


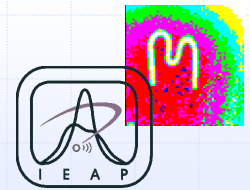
Pixel-saturation level

Per pixel energy saturation level ~ 500 keV independent of impact angle and bias



Measured energy vs. expected energy

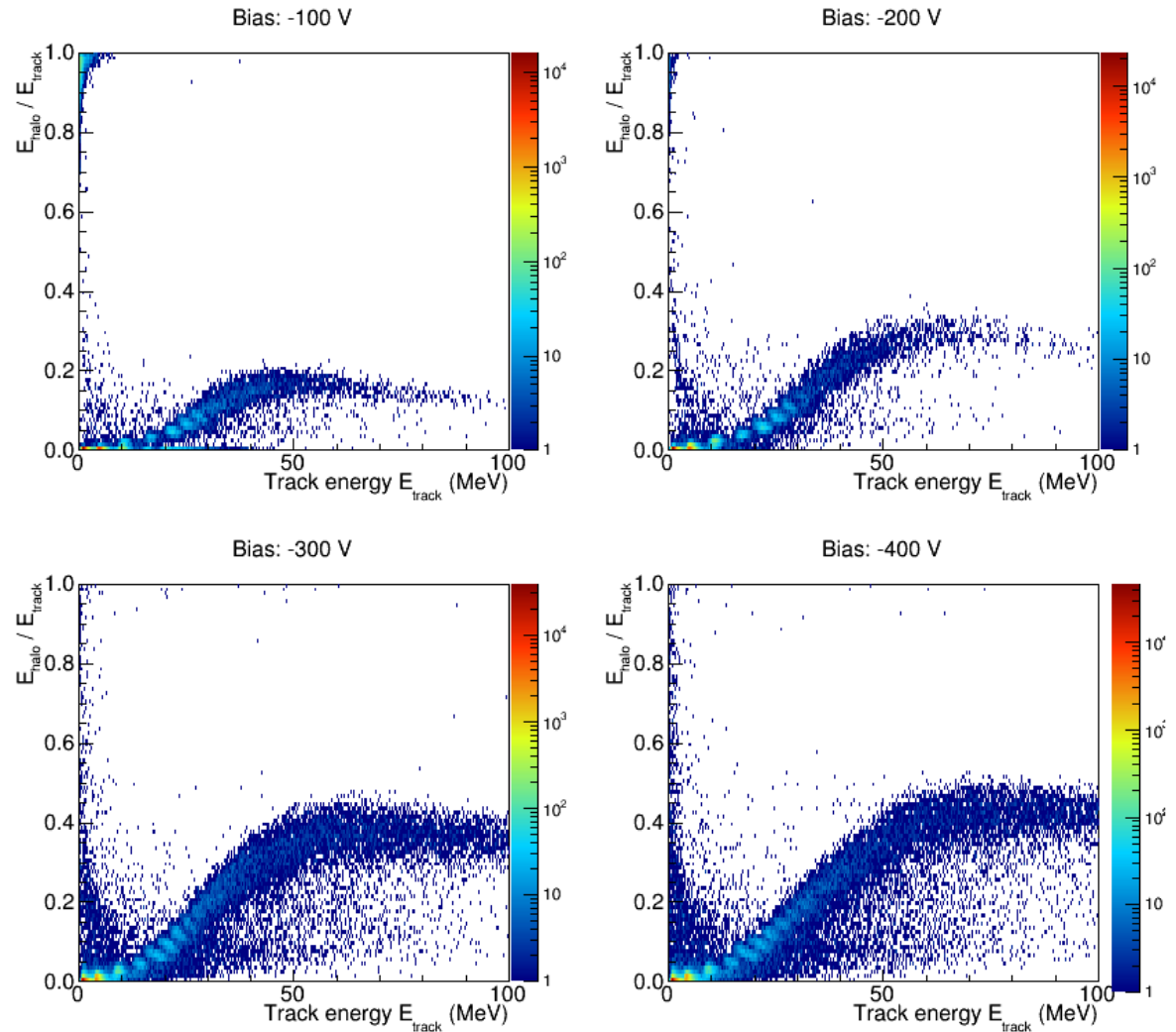




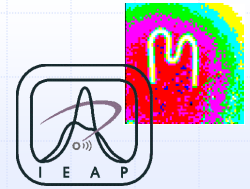
Halo vs. energy

Relative amount of energy in the halo increases with increasing energy deposition

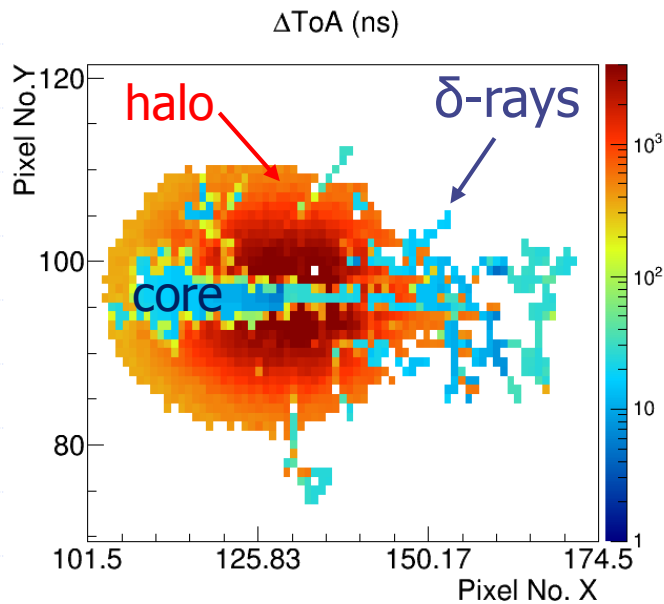
Relative amount of energy in the halo increases with increasing bias voltage



330 GeV/c Pb impact on target: Single heavy ion event – Features



- Initial track (core) with outgoing δ -rays surrounded by a halo of pixels with lower energy measurements



Halo pixels are seen with a delay in the order of μs

- Time structure can be used to easily separate core and halo
- Halo delay decreases with increasing bias voltage
- Halo pixels' timestamp decreases with increasing distance to the core

- Number of halo pixels and energy in the halo increases with increasing bias
- Energy in the halo increases with energy deposition

